

Appl. No. 10/810,023  
Amdt. Dated March 28, 2007  
Reply to Advisory Action of February 12, 2007

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**Amendments to the Specification**

Please replace paragraph [0023] with the following amended paragraph.

[0023] Referring also to FIGS. 4 and 5, each of barrier array portions 34 of which the barrier array is comprised is completed once an insulative layer 31 of alumina material has been deposited on the shadow mask 21 to a predetermined thickness. Each barrier array portion 34 comprises a part of the shadow mask 21 and the insulative layer 31 formed thereon. FIG. 5 shows a cross-sectional view of the barrier array portion 34 of FIG. 4 taken along line V-V thereof. The metal plate 25 and a peripheral sidewall of the opening 23 of the barrier array portion 34 [[is]] are, as shown in FIG. 5, directly coated and/or covered by the insulative layer 31. A thickness of the insulative layer 31 is in the range from 10 to 500 micrometers, and preferably is in the range from 75 to 200 micrometers.